

## Assignment 5: *pn* junctions

1. A Si *pn* junction of  $1 \text{ cm}^2$  area consists of a *n* region with  $10^{17}$  *donors cm*<sup>-3</sup> and a *p* region with  $2 \times 10^{17}$  *acceptors cm*<sup>-3</sup>. Calculate the
  - (a) Built-in potential
  - (b) Total depletion width
  - (c) Depletion widths on the *p* and *n* sides.

The junction is in equilibrium.

2. A *pn* junction diode has a concentration of  $10^{16}$  *acceptor atoms cm*<sup>-3</sup> on the *p*-side and  $10^{17}$  *donor atoms cm*<sup>-3</sup> on the *n* side. What will be the built-in potential for the semiconducting materials Ge, Si, and GaAs?

Semiconductor	$E_g$ (eV)	$n_i$ ( <i>cm</i> <sup>-3</sup> )
Ge	0.7	$2.40 \times 10^{13}$
Si	1.1	$1.0 \times 10^{10}$
GaAs	1.4	$2.10 \times 10^6$

3. A Si abrupt junction in equilibrium at  $T = 300 \text{ K}$  is doped such that  $E_c E_F = 0.21 \text{ eV}$  in the *n* region and  $E_F E_v = 0.18 \text{ eV}$  in the *p* region. Take  $n_i = 10^{10} \text{ cm}^{-3}$ ,  $E_g = 1.10 \text{ eV}$ , and  $E_{Fi} = 0.55 \text{ eV}$ .
  - (a) Draw the energy band diagram of the junction.
  - (b) Determine the impurity doping concentrations in each region.
  - (c) Determine the built-in potential.
4. An abrupt *np*<sup>+</sup> junction diode has a cross sectional area of  $1 \text{ mm}^2$ , an acceptor concentration of  $5 \times 10^{18}$  boron *atoms cm*<sup>-3</sup> on the *p*-side and a donor concentration of  $10^{16}$  arsenic *atoms cm*<sup>-3</sup> on the *n*-side. The lifetime of holes in the *n*-region is  $417 \text{ ns}$ , whereas that of electrons in

the  $p$ -region is only  $5 \text{ ns}$ . Mean thermal generation lifetime is  $1 \text{ } \mu\text{s}$ .  $\mu_e = 120 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ ,  $\mu_h = 44 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ ,  $E_g = 1.1 \text{ eV}$ . The length of the  $p$  and  $n$  regions are  $5$  and  $100 \text{ } \mu\text{m}$  respectively.

- (a) Calculate the minority diffusion lengths and determine what type of diode this is.
  - (b) What is the built-in potential across the junction?
  - (c) What is the current when there is a forward bias of  $0.6 \text{ V}$  across the diode? Take  $T = 300 \text{ K}$ .
  - (d) Estimate the forward current at  $373 \text{ K}$  when the voltage across the diode remains at  $0.6 \text{ V}$ . Assume temperature dependence of  $n_i$  dominates  $D, L$ , and  $\mu$ .
  - (e) What is the reverse current when the diode is reverse biased by a voltage  $V_r = 5 \text{ V}$ ?
5. A Ge  $p^+n$  diode at  $T = 300 \text{ K}$  has the following parameters:  $N_A = 10^{18} \text{ cm}^{-3}$ ,  $N_D = 10^{16} \text{ cm}^{-3}$ ,  $D_h = 49 \text{ cm}^2\text{s}^{-1}$ ,  $D_e = 100 \text{ cm}^2\text{s}^{-1}$ ,  $\tau_h = \tau_e = 5 \mu\text{s}$ , and  $A = 10^{-4} \text{ cm}^2$ . Determine the diode current for a forward bias voltage of  $0.2 \text{ V}$ . Take  $n_i = 2.4 \times 10^{13} \text{ cm}^{-3}$ .